	Application No.	Applicant(s)	
Notice of Allowability	10/669,378	LIM, BYOUNG HO	
	Examiner	Art Unit	
	Tai Duong	2871	
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to	olication. If not included will be mailed in due course. THIS	√e
1. This communication is responsive to <u>Amendment 05/09/05</u>	į,		
2. The allowed claim(s) is/are 1 and 3-15.			
3. \boxtimes The drawings filed on <u>25 September 2003</u> are accepted by	the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority una a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 	been received.		
3. Copies of the certified copies of the priority do	• • • • • • • • • • • • • • • • • • • •		
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		complying with the requirements	
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give			
 CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1. 	on's Patent Drawing Review (PTO- s Amendment / Comment or in the C	ffice action of	
each sheet. Replacement sheet(s) should be labeled as such in the			
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT 			
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. Notice of Informal P	atent Application (PTO-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary		
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0	Paper No./Mail Dat 8), 7. ☐ Examiner's Amendr		
Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiner's Stateme	nt of Reasons for Allowance	
of Biological Material	9. Other		

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REASONS FOR ALLOWANCE

Acknowledgment is made of applicant's claim for foreign priority based on an application filed in Korea on 10/05/02. It is noted, however, that applicant has not filed a certified copy of the Korean application as required by 35 U.S.C. 119(b).

The following is an examiner's statement of reasons for allowance:

Amended claim 1 is allowed over the prior art of record because it includes the allowable feature of claim 2, as set forth in the last Office action. Claims 3-8 are also allowed since they depend on the allowed claim 1.

Claims 9-13 stand allowed for the same reasons set forth in the last Office action.

Claim 14 is allowed over the prior art of record because none of the prior art discloses or suggests a LCD panel having the combination of the features "a plurality of pixel electrodes receiving data signals having different polarities from each other", " a semiconductor layer formed along a direction of each of the data lines at a lower part of the data lines to extend past edge portions of the data lines", and "a plurality of light-shielding patterns formed along the direction of the data lines to extend past edge portions of the data lines to extend past edge portions of the data lines".

Claim 15 is allowed over the prior art of record because none of the prior art discloses or suggests a method of fabricating a LCD panel having the combination of the steps "forming a gate electrode, a gate line, and individual first and second light-shielding patterns on a substrate", "forming a semiconductor layer on the gate insulating film to partially overlap the individual first and second light-shielding patterns", and

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"forming a data line on the gate insulating film to partially overlap the individual first and second light-shielding patterns and the semiconductor layer".

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication should be directed to Tai Duong at telephone number (571) 272-2291.

The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

DUNGT NGUYEN

TVD

06/05